



June 24th			
	Medium Hall	Small Hall	Room 407
9:00			
9:15			
9:30	Opening 9:30-9:45		
9:45	Award 9:45-10:00		
10:00	E0. Plenary Talk 10:00-11:30		
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13:00	E2 EUV Lithography 13:00-14:40	E12 Fundamentals and Applications of Biomimetics Materials and Processes 13:00-14:40	
13:15			
13:30			E11 Organic and Hybrid Materials for Photovoltaic and Optoelectronic Devices 13:30-15:25
13:45			
14:00	Coffee Break	Coffee Break	
14:15			
14:30			
14:45			
15:00	E2 EUV Lithography 14:55-15:55	E12 Fundamentals and Applications of Biomimetics Materials and Processes 15:00-16:00	Coffee Break
15:15			
15:30			
15:45			
16:00	Coffee Break		E11 Organic and Hybrid Materials for Photovoltaic and Optoelectronic Devices 15:40-17:20
16:15	E4 Computational / Analytical Approach for Lithography Processes 16:10-18:10		
16:30			
16:45			
17:00			
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18:00			
18:15	Coffee Break		
18:30	Panel Symposium 18:30-20:00		
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19:00			
19:15			
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20:00			

**June 25th**

	Medium Hall	Small	Room 407	Room 408		
9:00						
9:15						
9:30	<b>E2</b> EUV Lithography  9:30-11:30	<b>E7</b> Strategies, Materials, and Processes for Advanced Packaging, MEMS, and Flexible Devices  9:20-11:25	<b>E11</b> Organic and Hybrid Materials for Photovoltaic and Optoelectronic Devices  9:30-11:00	<b>E13, J1</b> Surface Treatment and Functionalization of Polymer Surfaces 9:20-10:20		
9:45					<b>Coffee Break</b>	
10:00						<b>E13, J1</b> Surface Treatment and Functionalization of Polymer Surfaces 10:30-11:30
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11:00			<b>Coffee Break</b>			
11:15						
11:30			<b>E11</b> Organic and Hybrid Materials for Photovoltaic and Optoelectronic Devices  11:15-12:30			
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13:00	<b>E2</b> EUV Lithography  13:00-15:00	<b>E8</b> Polyimides and High Thermally Stable Resins  13:00-14:20	<b>E10</b> Photopolymers in 3-D Printing/ Additive Manufacturing  13:30-14:50	<b>E13, J1</b> Surface Treatment and Functionalization of Polymer Surfaces 13:30-14:20		
13:15					<b>Coffee Break</b>	
13:30					<b>E13, J1</b> Surface Treatment and Functionalization of Polymer Surfaces 14:30-15:30	
13:45			<b>E7</b> Strategies, Materials, and Processes for Advanced Packaging, MEMS, and Flexible Devices  14:30-16:00			
14:00			<b>Coffee Break</b>			
14:15						
14:30	<b>Coffee Break</b>					
14:45			<b>Coffee Break</b>			
15:00						
15:15	<b>E1</b> Next Generation Lithography and EB Lithography  <b>E3</b> DUV Lithography  15:15-17:05		<b>E10</b> Photopolymers in 3-D Printing/ Additive Manufacturing  15:00-16:30			
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17:30	<b>Banquet</b>  17:30-20:00					
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June 26th				
	Medium Hall	Small Hall	Room 407	
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9:30	<b>E5</b> Directed Self Assembly (DSA)  <b>9:30-11:40</b>	<b>E9</b> Nanobiotechnology  <b>9:30-12:00</b>	<b>E6</b> Nanoimprint  <b>9:30-10:30</b>	
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13:00	<b>E2</b> EUV Lithography  <b>13:00-14:50</b>			
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13:30				<b>E14</b> Chemistry for Advanced Photopolymer Science <b>13:30-14:30</b>
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14:30		<b>Coffee Break</b>		
14:45	<b>Coffee Break</b>			
15:00	<b>E2</b> EUV Lithography  <b>15:05-16:45</b>		<b>E14</b> Chemistry for Advanced Photopolymer Science  <b>14:50-16:10</b>	
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16:45	<b>Closing Remark 16:45-16:55</b>			
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